

POLISHING CLOTHS

- Used for rough and fine polishing during metallographic sample preparation
- Applicable to metallographic polishing machines of all models and specifications



Part NO.	Material	Description	Size	Package (pcs/box)
MLP-CT1	velvet	1. chemical fiber material, with 7 μ m~2.5 μ m diamond oxide abrasives selected 2. for common polishing of steel materials	7.87"DIA (PSA)	15 pcs
MLP-CT2			9.84"DIA (PSA)	15 pcs
MLP-CT3			11.81"DIA (PSA)	15 pcs
MLP-CT4			9.84"DIA	15 pcs
MLP-CT5			11.81"DIA	15 pcs
MLP-CT6	velvet	1. silk material, with 3.5 μ m~0.5 μ m diamond abrasives selected, or 1 μ m~0.05 μ m oxide abrasives 2. for polishing steel, hard metals, metal alloys, metallographic slices of metals, or high precision materials	7.87"DIA (PSA)	15 pcs
MLP-CT7			9.84"DIA (PSA)	15 pcs
MLP-CT8			11.81"DIA (PSA)	15 pcs
MLP-CT9			9.84"DIA	15 pcs
MLP-CT10			11.81"DIA	15 pcs
MLP-CT11	velveteen	1. short - pile material, with 10 μ m~5 μ m diamond and oxide abrasives selected 2. for polishing steel materials or materials such as electronic circuit boards, copper, aluminum, and magnesium	7.87"DIA (PSA)	15 pcs
MLP-CT12			9.84"DIA (PSA)	15 pcs
MLP-CT13			11.81"DIA (PSA)	15 pcs
MLP-CT14			9.84"DIA	15 pcs
MLP-CT15			11.81"DIA	15 pcs
MLP-CT16	flocking	1. short-pile material, with 7 μ m~2.5 μ m diamond and oxide abrasives selected 2. for polishing materials such as steel, metal alloys, non metals, polymers, ceramics, electronic components, heat-treated surfaces, and metallographic slices of metals	7.87"DIA (PSA)	15 pcs
MLP-CT17			9.84"DIA (PSA)	15 pcs
MLP-CT18			11.81"DIA (PSA)	15 pcs
MLP-CT19			9.84"DIA	15 pcs
MLP-CT20			11.81"DIA	15 pcs
MLP-CT21	silk	1. silk material, with 1 μ m~0.05 μ m diamond and oxide abrasives selected 2. for precision mirror polishing of ferrous metals, non-ferrous metals, coatings, plastics, polymers and all materials of medium hardness	7.87"DIA (PSA)	15 pcs
MLP-CT22			9.84"DIA (PSA)	15 pcs
MLP-CT23			11.81"DIA (PSA)	15 pcs
MLP-CT24			9.84"DIA	15 pcs
MLP-CT25			11.81"DIA	15 pcs
MLP-CT26	wool fabric	1. wool material, with 5 μ m~3 μ m diamond and oxide abrasives selected 2. for fine polishing of soft non-ferrous metal materials or polishing of steel materials	7.87"DIA (PSA)	15 pcs
MLP-CT27			9.84"DIA (PSA)	15 pcs
MLP-CT28			11.81"DIA (PSA)	15 pcs
MLP-CT29			9.84"DIA	15 pcs
MLP-CT30			11.81"DIA	15 pcs
MLP-CT31	nylon	1. chemical fiber material, with 10 μ m~5 μ m diamond and oxide abrasives selected 2. for polishing of glass electrodes, carbides, non-metallic metallographic slice materials and general polishing of steel materials	7.87"DIA (PSA)	15 pcs
MLP-CT32			9.84"DIA (PSA)	15 pcs
MLP-CT33			11.81"DIA (PSA)	15 pcs
MLP-CT34			9.84"DIA	15 pcs
MLP-CT35			11.81"DIA	15 pcs

CODE	Material	Description	Size	Package (pcs/box)
MLP-CT36	canvas	1. pure cotton material, with 14 μ m~7 μ m diamond, oxide and other abrasives selected 2. for primary rough polishing of steel materials, non-ferrous metals and cemented carbides	7.87"DIA (PSA)	15 pcs
MLP-CT37			9.84"DIA (PSA)	15 pcs
MLP-CT38			11.81"DIA (PSA)	15 pcs
MLP-CT39			9.84"DIA	15 pcs
MLP-CT40			11.81"DIA	15 pcs
MLP-CT41	rubber	1. rubber material, with 1 μ m~0.05 μ m oxide abrasives selected 2. for polishing materials such as non-ferrous metals, optical fibers, gemstones and crystals, and optical glass	7.87"DIA (PSA)	10 pcs
MLP-CT42			9.84"DIA (PSA)	10 pcs
MLP-CT43	polyurethane	1. polyurethane material, with 9 μ m~2 μ m diamond and oxide abrasives selected 2. for polishing materials such as glass, silicon wafers, and crystals	7.87"DIA (PSA)	10 pcs
MLP-CT44			9.84"DIA (PSA)	10 pcs